


Certificate of Test

KICET	Certificate No. : 2013-3435-1 Page(1)/(1)Pages	
77, Digital road 16, Guemcheon-Gu, Seoul, Korea (Tel: +82 02 3282 2416/7, Fax: +82 02 3282 2418)		

1. Client

- Company/Name : M&C DENTAL CO., LTD. / Chang-taek Lee
- Address : #B-314, 315 SK Twintech Tower, Gasan-dong, Geumcheon-gu, Seoul, KOREA.
- Date of Receipt : Dec. 09. 2013

2. Use of Report : Quality control

3. Test Sample : Surface Etched Zirconia

4. Date of Test : Dec. 09. 2013 ~ Dec. 17. 2013

5. Test method used : Presented by customer

6. Testing Environment

- Temperature : 15 °C ± 1 °C , Relative Humidity : 32 % R.H. ± 1 % R.H.

7. Test Results

Sample name	Item	Results	Test Method	Remark
Surface Etched Zirconia	Bond strength (MPa)	36 ± 1	Presented by customer	


* Presented by customer : Push-Pull Tention Gauge 5005.

Affirmation	Tested by Name : K. I. Choi <i>최기인</i>	Technical Manager Name : D. W. Park <i>Park D W</i>
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Dec. 17. 2013

Korea Institute of Ceramic Engineering & Technology

Certificate of Test

KICET 77, Digital road 16, Guemcheon-Gu, Seoul, Korea (Tel: +82 02 3282 2416/7, Fax: +82 02 3282 2418)	Certificate No. : 2013-3435-2 Page(1)/(1)Pages	
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1. Client

- Company/Name : M&C DENTAL CO., LTD. / Chang-taek Lee
- Address : #B-314, 315 SK Twintech Tower, Gasan-dong, Geumcheon-gu, Seoul, KOREA.
- Date of Receipt : Dec. 09. 2013

2. Use of Report : Quality control

3. Test Sample : Normal Surface Zirconia

4. Date of Test : Dec. 09. 2013 ~ Dec. 17. 2013

5. Test method used : Presented by customer

6. Testing Environment

- Temperature : 15 °C ± 1 °C , Relative Humidity : 32 % R.H. ± 1 % R.H.

7. Test Results

Sample name	Item	Results	Test Method	Remark
Normal Surface Zirconia	Bond strength (MPa)	30 ± 1	Presented by customer	

* Presented by customer : Push-Pull Tention Gauge 5005.

Affirmation	Tested by Name : K. I. Choi <i>최기인</i>	Technical Manager Name : D. W. Park <i>박동우</i>
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Dec. 17. 2013

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